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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/672,551	09/26/2003	Seiji Funaba	17072	3724

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EXAMINER	
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2826	

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Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Office Action Summary	Application No.	Applicant(s)	
	10/672,551	FUNABA ET AL.	
	Examiner	Art Unit	
	Ben P. Sandvik	2826	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1)☒ Responsive to communication(s) filed on *7/2/2008*.

2a)☐ This action is **FINAL**. 2b)☒ This action is non-final.

3)☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4)☒ Claim(s) *1-54 and 56-74* is/are pending in the application.

4a) Of the above claim(s) *See Continuation Sheet* is/are withdrawn from consideration.

5)☐ Claim(s) _____ is/are allowed.

6)☒ Claim(s) *1,2,5,7,60,61 and 72* is/are rejected.

7)☒ Claim(s) *11 and 68* is/are objected to.

8)☐ Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9)☐ The specification is objected to by the Examiner.

10)☐ The drawing(s) filed on _____ is/are: a)☐ accepted or b)☐ objected to by the Examiner.

Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).

Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).

11)☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12)☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).

a)☐ All b)☐ Some * c)☐ None of:

1.☐ Certified copies of the priority documents have been received.

2.☐ Certified copies of the priority documents have been received in Application No. _____.

3.☐ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1) ☒ Notice of References Cited (PTO-892)
2) ☐ Notice of Draftsperson's Patent Drawing Review (PTO-948)
3) ☒ Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date *9/2/2008*.
4) ☐ Interview Summary (PTO-413) Paper No(s)/Mail Date. _____.
5) ☐ Notice of Informal Patent Application
6) ☐ Other: _____.

Continuation of Disposition of Claims: Claims withdrawn from consideration are 3,4,6,8-10, 12,15,16,18,20-22,24,26-30,32-34,36-54,56-71 and 73.

DETAILED ACTION

Response to Arguments

Applicant's arguments with respect to claims 1, 60, 61, and 72 have been considered but are moot in view of the new ground(s) of rejection.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

> (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 60, and 72 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lin (U.S. Patent #6383916), in view of Shiraishi et al (U.S. PG Pub #2001/0002727).

With respect to **claim 1**, Lin teaches a semiconductor unit having two device terminals for every one input/output signal (Fig. 10, 101-105 and 121-125), said semiconductor unit comprising: a laminated substrate (Fig. 10, 130 and Col 7 Ln 21-23, the substrate is multi-layer) comprising at least two wiring layers which include a signal wiring layer and a power-supply or ground wiring layer (Col 7 Ln 65-67), said laminated substrate having a main surface, a semiconductor chip (Fig. 10, 100) having an input/output pad (Fig. 5 and Col 6 Ln 21-23 and Fig. 7, 6) and being mounted on the main surface of said laminated substrate through said input/output pad, said two device terminals being mounted

on said laminated substrate and being connected to both ends of a signal wire in said signal wiring layer (Fig. 10, 131), but does not explicitly disclose that said signal wire is connected to the input/output pad of said semiconductor chip through a via hole formed in the laminated substrate. Shiraishi teaches a substrate wherein the wiring layers are connected to the chip through a via hole (Fig. 4, 109 and Paragraph 44). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use via holes in the substrate of Lin as taught by Shiraishi in order to achieve the predictable result of reducing wiring length.

With respect to **claim 60**, Lin teaches a semiconductor unit having two device terminals for every one input/output signal (Fig. 10, 101-105 and 121-125), said semiconductor unit comprising: a laminated substrate (Fig. 10, 130 and Col 7 Ln 21-23, the substrate is multi-layer) comprising at least two wiring layers which include a signal wiring layer and a power-supply or ground wiring layer (Col 7 Ln 65-67), said laminated substrate having a main surface, a semiconductor chip (Fig. 10, 100) having an input/output pad (Fig. 5 and Col 6 Ln 21-23 and Fig. 7, 6) and being mounted on the main surface of said laminated substrate through said input/output pad, said two device terminals being disposed on the main surface (Fig. 10, 101-105) and the back surface (Fig. 10, 121-125) of said laminated substrate opposite to each other, respectively, said signal wire being connected to the input/output pad of said semiconductor chip through a wire (Fig. 10, 131); but Lin does not explicitly disclose that said signal

wire is connected to the input/output pad of said semiconductor chip through a via hole formed in the laminated substrate, both the via hole and wire being formed in said laminated substrate. Shiraishi teaches a substrate wherein the wiring layers are connected to the chip through a via hole (Fig. 4, 109 and Paragraph 44). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use via holes in the substrate of Lin as taught by Shiraishi in order to achieve the predictable result of reducing wiring length.

With respect to **claim 72**, Lin teaches a semiconductor unit comprising a semiconductor chip having an input/output pad (Fig. 10, 100) and a package having a main surface and a back surface (Fig. 10, 130), said package having at least two ball terminal adhesive areas for every one input/output signal on the main and back surfaces of said package (Fig. 10, area of wires 131 which are on the main and back surfaces of substrate 130 and connect to ball terminals), a ball terminal (Fig. 10, 101-105 and 121-125) being adhered to only one ball terminal adhesive area on one surface of said package; said two ball terminal adhesive areas being connected to each through a vertical connection, said vertical connection being connected to the input/output pad of said semiconductor chip through a wire (Fig. 10, 131); but does not explicitly disclose that the vertical connection is a via hole. Shiraishi teaches a substrate wherein the wiring layers are connected to the chip through a via hole (Fig. 4, 109 and Paragraph 44). It would have been obvious to one of ordinary skill in the art at the time the

invention was made to use via holes in the substrate of Lin as taught by Shiraishi in order to achieve the predictable result of reducing wiring length.

Claims 2 and 61 are rejected under 35 U.S.C. 103(a) as being unpatentable over Lin and Shiraishi, in view of Yew et al (U.S. Patent #6137164).

With respect to **claim 2**, Lin does not teach that the semiconductor chip comprises a circuit comprising at least one of an input buffer and an output buffer, an input protection resistor, and an electrostatic protection element. Yew teaches a chip having a layer of polymeric chip coating material (Col 6 Ln 39-41). It would have been obvious to one of ordinary skill in the art at the time the invention was made to provide a layer of polymeric chip coating material to the chip of Lin as taught by Yew in order to give the chip electrostatic protection.

With respect to **claim 61**, Lin teaches a semiconductor unit having two device terminals for every one input/output signal (Fig. 10, 101-105 and 121-125), said semiconductor unit comprising: a laminated substrate (Fig. 10, 130 and Col 7 Ln 21-23, the substrate is multi-layer) comprising at least two wiring layers which include a signal wiring layer and a power-supply or ground wiring layer (Col 7 Ln 65-67), said laminated substrate having a main surface and a back surface, a semiconductor chip (Fig. 10, 100) having an input/output pad (Fig. 5 and Col 6 Ln 21-23 and Fig. 7, 6) and being mounted on the main surface of said laminated substrate, said two device terminals being disposed on the main surface (Fig. 10, 101-105) and the back surface (Fig. 10, 121-125) of said

laminated substrate opposite to each other; but Lin does not teach that there are two semiconductor chips mounted on main and back surfaces of said laminated substrate, or that said two device terminals are connected to each through a via hole. Shiraishi teaches a substrate wherein the wiring layers are connected to each other and to the chip through via holes (Fig. 4, 109 and Paragraph 44). It would have been obvious to one of ordinary skill in the art at the time the invention was made to use via holes in the substrate of Lin as taught by Shiraishi in order to achieve the predictable result of reducing wiring length.

Yew teaches a substrate having two semiconductor chips mounted on the main surface and back surface respectively (Fig. 5 and Abstract). It would have been obvious to one of ordinary skill in the art at the time the invention was made to provide two semiconductor chips on the package of Lin as taught by Yew in order to improve the package density of the device (Col 3 Ln 25-29).

Claim 5 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lin and Shiraishi, in view of Devnani (U.S. Patent #6630628).

With respect to **claim 5**, Lin does not teach that the signal wiring layer forms a micro-strip line with the ground wiring layer in said laminated substrate, said ground wiring layer being disposed between said signal wiring layer and said semiconductor chip. Devnani teaches that the signal layer forms a micro strip line and that the ground wiring layer (Fig. 2, 140) is disposed between the signal layer (Fig. 2, 150) and the semiconductor chip (Fig. 2, 105). It would have

been obvious to one of ordinary skill in the art at the time the invention was made to arrange the signal and ground layers of Lin as taught Devnani in order to optimize the wiring arrangement of the substrate.

Claim 7 is rejected under 35 U.S.C. 103(a) as being unpatentable over Lin, in view of Tanahashi (U.S. Patent #6184477).

With respect to **claim 7**, Lin does not teach said signal wiring layer being sandwiched between the power-supply layer and the ground layer in said laminated substrate, said signal wiring layer forming a strip line with the power-supply layer or the ground layer. Tanahashi teaches a signal layer (Fig. 6, S1) between a power layer (Fig. 6, P) and a ground layer (Fig. 6, G), the signal layer forming a strip line (Fig. 5, S1). It would have been obvious to one of ordinary skill in the art at the time the invention was made to arranged the wiring layers of Lin as taught by Tanahashi in order to optimize the electrical characteristics of the device.

Allowable Subject Matter

Claims 13, 14, 17, 19, 23, 25, 31, 35, and 74 are allowed.

Claims 11 and 68 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Ben P. Sandvik whose telephone number is (571) 272-8446. The examiner can normally be reached on Mon-Fri.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Sue Purvis can be reached on 571-272-1236. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/B. P. S./
Examiner, Art Unit 2826

/Evan Pert/
Primary Examiner, Art Unit 2826